IN THE CLAIMS:

1. (Cancelled).

2. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component comprises two cationically polymerizable functional

groups.

3. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said monomer portion of said first component is an organic monomer

selected from the group of aryl, norbornane, and combinations thereof.

4. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said monomer portion of said first component is an organosilicone

monomer containing (SiR2O) or (SiRO3/2) units, wherein R is hydrogen, a methyl group, a

phenyl group, a hydrocarbon, or a fluorocarbon group.

5. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said cationically polymerizable functional group of said first component is

selected from the group of epoxy functional groups, vinyl ether functional groups, and

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combinations thereof.

6. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component is

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$$\left[\begin{array}{c|c} CH_3 \\ Si \\ CH_3 \end{array}\right]_2 O$$

- (Currently Amended) A material composition An article as set forth in claim
 wherein said crosslinker comprises four cationically polymerizable functional groups.
- (Currently Amended) A material composition An article as set forth in claim
 [[1]]36 wherein said crosslinker comprises silicone.
- (Currently Amended) A material composition An article as set forth in claim
 [[1]]36 wherein said cationically polymerizable function groups of said crosslinker are
 selected from the group of epoxy functional groups, vinyl ether functional groups, and
 combinations thereof.
- (Currently Amended) A material composition An article as set forth in claim
 [[1]]36 wherein said crosslinker is

$$\left[\begin{array}{c} CH_3 \\ Si \\ CH_3 \end{array}\right]_4 Si$$

H&H No.: 71,038-102 Serial No.: 10/598,943 11. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein first component and/or said crosslinker are the reaction product of 4-vinyl-

1-cyclohexane-1,2-epoxide and an SiH-functional silicone compound.

12. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said cationic photoinitiator comprises an active cationic species and an

anionic species, with said cationic species comprising an onium salt.

13. (Currently Amended) A material composition An article as set forth in claim 12

wherein said onium salt is a diaryliodonium salt, a triarylsulfonium salt, or a tetraaryl

phosphonium salt and said anionic species is selected from the group of BF4, PF6, AsF6,

SbF₆, and (C₆F₅)₄B.

14. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 wherein said first component is present from 90-98 parts by weight, said crosslinker

is present from 1-9 parts by weight, and said cationic photoinitiator is present from 0.1-2

parts by weight, all based on 100 parts by weight of said material composition.

15. (Currently Amended) A material composition An article as set forth in claim

[[1]]36 further comprising a non-reactive diluent for reducing a viscosity of said material

composition.

16. (Currently Amended) A material composition as set forth in claim 1 comprising:

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a first component having a monomer portion and at least one cationically polymerizable functional group;

a crosslinker reactive with said first component and comprising at least three cationically polymerizable functional groups;

a cationic photoinitiator, and

a non-reactive diluent for reducing a viscosity of said material composition wherein said non-reactive diluent is selected from the group of PGMEApropylene glycol monomethyl ether acetate, PGMEpropylene glycol monomethyl ether, 2-heptanone, xylene, and combinations thereof.

(Cancelled)

(Currently Amended) A material composition An article as set forth in claim
 [[1]]36 wherein;

said first component comprises two epoxy functional groups and said monomer portion of said first component is an organosilicone monomer; and

said crosslinker comprises silicone and four epoxy functional groups.

19. (Currently Amended) A-material-composition An article as set forth in claim [[1]]36 wherein said composition is applied on a substrate to form a film by spin-coating, dip-coating, or spray-coating.

- 20. (Currently Amended) A material composition An article as set forth in claim [[1]]36 wherein said composition is applied on a substrate as liquid droplets prior to contact printing.
- 21. (Currently Amended) Use of the Amethod comprising the step of imprinting a material composition comprising:
- a first component having a monomer portion and at least one cationically polymerizable functional group;
- a crosslinker reactive with said first component and comprising at least three cationically polymerizable functional groups; and
- a cationic photoinitiator,
- of elaim 1 inthrough at least one of nanoscale contact printing, nanoimprint lithography (NIL), microimprint lithography, UV-assisted nanoimprint lithography, Step-and-Flash Nanoimprint Lithography (S-FIL), and combined-nanoimprint-and-photolithography.
- 22. (Currently Amended) Use of the material composition of claim 1 in A method as set forth in claim 21 wherein a tool selected from the group of contact aligners, nanoimprinters, bonding machines, and presses is used for the step of imprinting.
- 23. (Currently Amended) Use of the material composition of claim 1A method as set forth in claim 21 wherein the material is imprinted at temperatures between 0 and 100°C and/or at pressures less than 10 atmospheres.

24-34. (Cancelled)

(Currently Amended) A cured resist film An article as set forth in claim [[24]]36
 wherein said resist film is of the general formula;

36. (Currently Amended) An article comprising:

a substrate layer; and

a resist layer formed on said substrate layer and comprising the reaction product of thea material composition of claim 1comprising:

a first component comprising a monomer portion and at least one cationically polymerizable functional group;

a crosslinker reactive with said first component and comprising at least three cationically polymerizable functional groups; and

a cationic photoinitiator; and

an undercoating layer disposed between said substrate layer and said resist layer.

- 37. (Original) An article as set forth in claim 36 wherein said substrate layer is formed from silicon or glass.
 - 38. (Cancelled).
- 39. (Currently Amended) An article as set forth in claim [[38]]36 wherein said undercoating layer is formed from a polymer.
- (Original) An article as set forth in claim in claim 39 wherein said polymer comprises poly(methyl methacrylate).
 - 41-50. (Cancelled)

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